TRANSMITTAL FORM



Electronic Version 1.0.2

Stylesheet Version: 1.0

Attorney Docket Number: BUR920000077

SINGLE REACTOR, MULTI-PRESSURE CHEMICAL VAPOR DEPOSITION FOR SEMICONDUCTOR DEVICES

First Named Inventor: Jack Chu

SUBMITTED BY

Name:

Mr. Robert A. Walsh Esq.

Registration Number:

26,516

Electronic Signature Mark: Robert A.

Date Signed: 20011116

. Walsh /s/

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Attached Files:

bibd-transmittal

BUR920000077US1 apds.xml

fee-transmittal

BUR920000077US1fee.xml

patent-assignment

BUR920000077US1asgn.xml

specification

BUR920000077US1.xml

declaration

BUR920000077 Dec. 1.tif

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declaration

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ASSIGNEE: INTERNATIONAL BUSINESS MACHINES CORPORATION ASSIGNEE ADDRESS: ARMONK, NY 10504

FEE TRANSMITTAL

Electronic Version 1.1.0 Stylesheet Version: 1.0

Patent fees are subject to annual revisions on or about October 1st of each year.

Large Entity

TOTAL FEES AUTHORIZED: \$ 780

The commissioner is hereby authorized to charge indicated processing and/or publication fees and credit any overpayments to:

Deposit Account Number: 09-0456

Deposit Account Name:

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Charge Any Additional Fee Required Under 37 C.F.R. Sections 1.16 and 1.17.

SUBMITTED BY

Authorized Name:

Robert A. Walsh

Electronic Signature Mark:

Robert A. Walsh /s/

Date Signed:

20011115

BASIC FILING FEE

Fee Description	Fee Code	Fee Paid	
Utility Filing Fee	101	\$ 740	
			

Subtotal For Basic Filing Fee: \$ 740

EXTRA CLAIM FEES

	Fee Code	Fee	Extra Claims	Fee Paid
Total Claims: 20	103	\$ 18	0	\$ 0
Independent Claims: 2	102	\$ 84	0	\$ 0

Subtotal For Extra Claims Fees: \$ 0



Fee Description	Fee Code	Fee Paid
Recording Each Patent Assignment Per Property Fee	581	\$ 40

Subtotal For Additional Fees: \$ 40



EFS ID:

12989

Application ID:

09683088

SINGLE REACTOR, MULTI-

Title of Invention: PRESSURE CHEMICAL VAPOR

DEPOSITION FOR

SEMICONDUCTOR DEVICES

First Named Inventor:

Jack Chu

☐ Domestic/Foreign Application:

Domestic Application

Filing Date:

null

Effective Receipt Date:

2001-11-16

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Submission Type:

Utility Patent Filing

🛱 Filing Type:

new-utility

Confirmation Number:

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